Special Issue

Advanced Dental Materials and Appliances

Message from the Guest Editors

We are inviting submissions to a Special Issue on Advanced Dental Materials and Appliances. Materials Science is constantly developing in dentistry. In the last years, innovative techniques have been developed thanks to the introduction of new materials. On the other hand, characteristics of materials already in current use are still unknown and some materials could have new uses in the different branches of dentistry. In addition, recent developments in the area of digital dentistry have revolutionised the workflow and manufacture of all dental branches. However, there is poor scientific evidence on the use of new technologies and digital appliances: hence, there is an absolute need for more research on this issue. In this Special Issue, we invite research and recent advances in the fields of advanced dental materials. Both theoretical and experimental studies are welcome, as well as comprehensive review and survey papers.

Guest Editors

Prof. Dr. Stefano Martina

Dr. Roberto Rongo

Dr. Mario Caggiano

Deadline for manuscript submissions

closed (20 April 2023)



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Message from the Editor-in-Chief

As the world of science becomes ever more specialized, researchers may lose themselves in the deep forest of the ever increasing number of subfields being created. This open access journal Applied Sciences has been started to link these subfields, so researchers can cut through the forest and see the surrounding, or quite distant fields and subfields to help develop his/her own research even further with the aid of this multi-dimensional network.

Editor-in-Chief

Prof. Dr. Giulio Nicola Cerullo

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